

Number	Hits	Search Text	DB	Time stamp
1	4	((anti near reflective near coating near layer) with (silicon near carbide or SiC) and (dual near damascene) not (@ad>20010628 or @rlad>20010628)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/09 12:13
	2	(photoresist or (photo near resist)) same (poisoned or poisoning or poison) and (dual near damascene) and (((silicon near carbide) or SiC) with nitrogen)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/09 12:01
	259	damascene and (SiCN or (silicon near carbide near nitride))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/27 15:01
	0	damascene and ((SiCN or (silicon near carbide near nitride)) same barrier) and (poison with (photoresist or (photo near resist)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/27 15:03
	117	damascene and ((SiCN or (silicon near carbide near nitride)) same barrier)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/27 15:03
	11	(barrier near layer) same (SiCN or "silicon carbide nitride") same (SiC or "silicon carbide")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/28 12:54
	197	maydan.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/28 12:55
	104	maydan.in. and semiconductor	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/28 12:55
	69	(maydan.in. and semiconductor) and apparatus	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/28 12:55
	2	"20020106895"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/07 15:50
	306	((438/638) or (438/637) or (438/627) or (438/702)).CCLS.) and (silicon near carbide or SiC)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/07 16:23
	51	(dual near damascene) and (SiCN or "silicon carbide nitride") same (SiC or "silicon carbide")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/07 16:34
	3191	((438/638) or (438/637) or (438/627) or (438/702)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/07 16:49
	83	(anti near reflective near coating near layer) and (dual near damascene)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/09 12:02

59	((anti near reflective near coating near layer) and (dual near damascene)) not (@ad>20010628 or @rlad>20010628)	USPAT; US-POGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/09 12:12
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